

ALEXANDRIA, VA 22314

# United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERC United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

FILING DATE FIRST NAMED INVENTOR ATTORNEY DOCKET NO. CONFIRMATION NO. APPLICATION NO. 10/721,876 11/26/2003 LAIM 3007/EM 6015 Ming-Jiunn Lai **EXAMINER** 23364 12/20/2005 **BACON & THOMAS, PLLC** LUM, LEON YUN BON **625 SLATERS LANE** ART UNIT PAPER NUMBER FOURTH FLOOR

1641
DATE MAILED: 12/20/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

|   | Application No.  | Applicant(s)        |     |
|---|--|---------------------|-----|
| Office Action Summary   | 10/721,876   | LAI ET AL.          |     |
|   | Examiner   | Art Unit            |     |
|   | Leon Y. Lum  | 1641                |     |
| The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply  |  |                     |     |
| A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). |  |                     |     |
| Status  |  |                     |     |
| <ul> <li>1) Responsive to communication(s) filed on <u>26 September 2005</u>.</li> <li>2a) This action is <b>FINAL</b>.</li> <li>2b) This action is non-final.</li> <li>3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i>, 1935 C.D. 11, 453 O.G. 213.</li> </ul>  |  |                     |     |
| Disposition of Claims   |  |                     |     |
| 4)  Claim(s) 1-35 is/are pending in the application 4a) Of the above claim(s) 1-24 is/are withdraw 5)  Claim(s) is/are allowed. 6)  Claim(s) 25-35 is/are rejected. 7)  Claim(s) is/are objected to. 8)  Claim(s) are subject to restriction and/o Application Papers  9)  The specification is objected to by the Examin 10)  The drawing(s) filed on 26 November 2003 is/s  | or election requirement.   | ed to by the Examin | er. |
| Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.   |  |                     |     |
| Priority under 35 U.S.C. § 119  |  |                     |     |
| <ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No.</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>  |  |                     |     |
| Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Paper No(s)/Mail Date  | 4) Interview Summary Paper No(s)/Mail Da  5) Notice of Informal F  6) Other: | ate                 | 52) |

Art Unit: 1641

### **DETAILED ACTION**

#### Election/Restrictions

1. Applicant's election without traverse of Group IV, claims 25-35, in the reply filed on 26 September 2005 is acknowledged.

## Claim Rejections - 35 USC § 101

2. 35 U.S.C. 101 reads as follows:

Whoever invents or discovers any new and useful process, machine, manufacture, or composition of matter, or any new and useful improvement thereof, may obtain a patent therefor, subject to the conditions and requirements of this title.

3. Claim 25 is rejected under 35 U.S.C. 101 because the claimed recitation of a use, without setting forth any steps involved in the process, results in an improper definition of a process, i.e., results in a claim which is not a proper process claim under 35 U.S.C. 101. See for example *Ex parte Dunki*, 153 USPQ 678 (Bd.App. 1967) and *Clinical Products, Ltd.* v. *Brenner*, 255 F. Supp. 131, 149 USPQ 475 (D.D.C. 1966).

# Claim Rejections - 35 USC § 112

4. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Art Unit: 1641

5. Claims 25-35 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

- 6. In claim 25, lines 1-6, the phrase "A structure of a nanodevice transistor for a biosensor, a detection area of a double gate nano device transistor being used for detecting an object so as to detect the specific bio species, the structure comprising" is vague and confusing. It is unclear whether one or multiple devices are being claimed. Is the nanodevice transistor (line 1) different from the double gate nano device transistor (line 2)?
- 7. Claim 25 recites the limitation "the specific bio species" in lines 4-5. There is insufficient antecedent basis for this limitation in the claim.
- 8. In claim 25, lines 8 and 10, the term "it" is vague and indefinite. In each of the lines, it is unclear as to what the instant term refers to.
- 9. Claim 25 recites the limitation "the boundary" in lines 15 and 18. There is insufficient antecedent basis for this limitation in the claim.

Art Unit: 1641

10. Claim 25 recites the limitation "the surface" in lines 28-29 and 32. There is insufficient antecedent basis for this limitation in the claim.

- 11. Claim 25 provides for the use of a first protection layer, a second protection layer, a first ceiling gate dielectric layer, a second ceiling gate dielectric layer, and a nano channel layer, but, since the claim does not set forth any steps involved in the method/process, it is unclear what method/process applicant is intending to encompass. A claim is indefinite where it merely recites a use without any active, positive steps delimiting how this use is actually practiced.
- 12. In claim 25, line 40, the term "the object" is vague and confusing. It is unclear whether the instant term is the same as the "object" in the previous line.
- 13. Claims 26 and 29-32 recite the limitation "the material". There is insufficient antecedent basis for this limitation in the claims.
- 14. Claim 27 recites the limitation "the refurbished nano channel". There is insufficient antecedent basis for this limitation in the claim.
- 15. In claims 29-32, the phrase "SiO<sub>x</sub>, SiN<sub>x</sub>" is vague and indefinite. Since the variable "x" is not defined in the claims or the specification, it is unclear exactly what chemical compounds are being claimed.

Art Unit: 1641

## Claim Rejections - 35 USC § 103

16. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

- 17. The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
  - 1. Determining the scope and contents of the prior art.
  - 2. Ascertaining the differences between the prior art and the claims at issue.
  - 3. Resolving the level of ordinary skill in the pertinent art.
  - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- 18. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

19. Claims 25-26 and 28-35 are rejected under 35 U.S.C. 103(a) as being unpatentable over Wada et al (US 2005/0056828 A1) in view of Snow et al (US 6,482,639 B2).

Wada et al reference teaches a MOS field effect transistor with a gate electrode 2 (i.e. bottom gate), a source electrode 4 (i.e. source), a drain electrode 5 (i.e. drain), and a channel layer 6 (i.e. nano channel layer), wherein the gate electrode is on a silicon substrate 1 (i.e. positioned on the silicon substrate), and the silicon substrate is layered with a gate insulating film 3 made of silicon oxide (i.e. gate dielectric layer; SiO<sub>2</sub> deposited on silicon substrate). See page 7, sections 0087-0092; and Figures 1A-C. Since the channel layer, source electrode, and drain electrode are on the silicon oxide layer, they are considered to read on the limitation wherein the nano channel layer, drain, and source are positioned on the gate dielectric layer.

However, Wada et al fail to teach a ceiling gate dielectric layer positioned on the drain and the source, comprising a first ceiling gate dielectric layer and a second ceiling gate dielectric layer, a ceiling gate positioned on the ceiling gate dielectric layer, a first protection layer positioned on the surface of the first ceiling gate dielectric layer, a second protection layer positioned on the surface of the second ceiling gate dielectric layer, wherein the first protection layer, the second protection layer, and the first ceiling gate dielectric layer, the second ceiling gate dielectric layer and the nano channel layer are used to define a detection area for detecting an object so as to achieve the object of detecting the specific bio species for biomeasurement.

Snow et al reference teaches layers 60 and 70 comprising SiO<sub>2</sub> and Si<sub>3</sub>N<sub>4</sub>, respectively (i.e. ceiling gate dielectric layer), electrode 50 (i.e. ceiling gate; metal), and layer 80 comprising SiO<sub>2</sub> (i.e. protection layer), in order to perform molecular recognition using label-free assay techniques capable of real-time analysis, has high sensitivity, high resolution, and is cost-effective. See column 1, lines 60-63; column 3, line 56 to column 4, line 3; column 5, lines 18-35; and Figure 1. Since the layer and electrode embodiments are separated by active sensing region 110, each of the embodiments are separately on top of source 12 and drain 14. The layers and electrode on top of the source are therefore considered to read on "first ceiling gate dielectric", "first ceiling gate", and "first protection layer", and the layers and electrode on top of the drain are considered to read on "second ceiling gate dielectric", "second ceiling gate", and "second protection layer".

It would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Wada et al with layers 60 and 70 comprising SiO<sub>2</sub> and Si<sub>3</sub>N<sub>4</sub>, respectively (i.e. ceiling gate dielectric layer), electrode 50 (i.e. ceiling gate), and layer 80 (i.e. protection layer), as taught by Snow et al, in order to perform molecular recognition using label-free assay techniques capable of real-time analysis, has high sensitivity, high resolution, and is cost-effective. The layers and electrodes of Snow et al have the advantage of providing a means to detect analytes without labels, thereby providing motivation to combine the layers and electrodes of Snow et al with the device of Wada et al. In addition, one of ordinary skill in the art at the time of the invention would have had reasonable expectation of success in including the embodiments of

Art Unit: 1641

Snow et al, in the device of Wada et al, since Wada et al teach a MOS field effect transistor, and the embodiments of Snow et al are also elements within a field effect transistor. Furthermore, the device of Wada et al provides a conducting path between the source and drain electrodes (see page 3, section 0049), and the layers of Snow et al isolate the source and drain from the substrate and protect them from the solution (see column 3, line 64 to column 4, line 1).

With respect to claim 26, Wada et al teach that gate 2 is polysilicon. See page 7, section 0091.

With respect to claim 33, Snow et al teach that electrode 50 covers both layers 60 and 70 (i.e. ceiling gate is any position on the ceiling gate dielectric layer). In addition, since the layers and electrode of Snow et al would completely cover the source and drain electrodes of Wada et al, the channel of Wada et al would necessarily be covered by the elements of Snow et al (i.e. ceiling gate covers a portion of the nano channel layer).

With respect to claims 34-35, Snow et al teach an array of sensors fabricated into a common substrate, wherein the sensors operate in parallel (i.e. plurality of double nano gate device transistors connected to form a serial connection structure). See column 2, lines 42-48; and column 5, lines 22-24.

20. Claim 27 is rejected under 35 U.S.C. 103(a) as being unpatentable over Wada et al (US 2005/0056828 A1) in view of Snow et al (US 6,482,639 B2) as applied to claim 25 above, and further in view of Tsuruta et al (US 5,066,582).

Art Unit: 1641

Wada et al and Snow et al references have been disclosed above, and Snow et al additionally teaches that antibodies are immobilized on the FET. See column 5, lines 1-7. However, Wada et al and Snow et al fail to teach that a surfactant is absorbed on the refurbished nano channel layer.

Tsuruta et al reference teaches surfactants to wash the binding region on a substrate, in order to provide a blocking means on the substrate. See column 8, lines 56-63.

It would have been obvious to one of ordinary skill in the art at the time of the invention to modify the device of Wada et al and Snow et al with surfactants to wash the binding region on a substrate, as taught by Tsuruta et al, in order to provide a blocking means on the substrate. The surfactants of Tsuruta et al provide the advantage of preventing non-specific binding of biomolecules onto the binding region of a substrate, thereby increasing the substrate's binding effectiveness and providing motivation to combine the surfactants with the device of Wada et al and Snow et al. In addition, one of ordinary skill in the art at the time of the invention would have had reasonable expectation of success in including the surfactants of Tsuruta et al, in the device of Wada et al and Snow et al, since Wada et al and Snow et al teach binding regions on a substrate, and the surfactants of Tsuruta et al are applied to binding regions.

## Conclusion

21. No claims are allowed.

Art Unit: 1641

22. The prior art made of record and not relied upon is considered pertinent to Applicants' disclosure:

Schenck (US 4,238,757) teaches a field effect transistor with source and drain electrodes to detect biological reactions.

Sohn (US 5,309,085) teaches a biosensor with an enzyme FET that includes a source, drain, and gate.

Goodman et al (US 6,627,154 B1) teach a sensor comprising multiple dielectric and conducting layers that form a sensor well.

Wu et al (US 6,716,642 B1) teach MOSFET biochips having arrays or immobilized biomolecules.

Kawarada (US 6,833,059 B2) teach an ISFET biosensor having a source, drain, and gate.

Yang et al (US 2004/0262636 A1) teach fluidic nanotube devices having a semiconductor with multiple gates.

Keersmaecker et al (US 2005/0053524 A1) teach a sensing device having double gate transistors.

23. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Leon Y. Lum whose telephone number is (571) 272-2878. The examiner can normally be reached on weekdays from 8:00am-5:00pm.

Application/Control Number: 10/721,876

Art Unit: 1641

Page 11

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Long Le can be reached on (571) 272-0823. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Leon Y. Lum Patent Examiner Art Unit 1641

LYL

LONG V. LE SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1600

12/09/05